

Amendments to the Specification:

Please replace the paragraph on page 1, line 4, with the following amended paragraph:

This application is a continuation of U.S. patent application Serial No. 10/622,905, filed July 18, 2003, which claims the benefit of U.S. provisional applications Serial Nos. 60/396,904 filed July 18, 2002; 60/413,622, filed September 25, 2002; 60/414,199, filed September 26, 2002; 60/423,750, filed November 5, 2002; 60/432,093, filed December 10, 2002; 60/432,962, filed December 12, 2002; 60/442,109, filed January 23, 2003; 60/449,791, filed February 24, 2003; 60/479,016, filed June 16, 2003, and 10/614,266, filed July 3, 2003 [(attorney docket No. 1662/60606)], the contents of all of which are incorporated herein by reference.

Please add the following after Page 8, Line 12.

Figure 65 is a XRPD pattern of nateglinide Form U prepared according to Example 17, lacking the impurity at 3.8 +/-0.2 shown in Figure 17.

Figure 66 is a XRPD pattern of nateglinide Form U prepared according to Example 17, lacking the impurity at 3.8 +/-0.2 shown in Figure 17.

Figure 67 is a XRPD pattern of nateglinide Form U prepared according to Example 17, lacking the impurity at 3.8 +/-0.2 shown in Figure 17.

Figure 68 is a XRPD pattern of nateglinide Form U prepared according to Example 17, lacking the impurity at 3.8 +/-0.2 shown in Figure 17.